## **Amendments to the Claims**

Claims 1-45 (Canceled)

Please add the following new claims:

46. (New) A polishing pad for polishing a surface, comprising:

a first member defining a first polishing surface and comprising a structurally degradable abrasive first material, the abrasive first material being randomly distributed throughout the first member; and

a second member defining a second polishing surface;

at least a portion of the first member capable of being extended beyond the second polishing surface by a fixed amount.

- 47. (New) The pad of claim 46, further comprising an opposing side formed from at least one of the first member and the second member.
  - 48. (New) The pad of claim 46, wherein:

the first member includes a plurality of first sections having first polishing surfaces; and

the second member includes a plurality of second sections having second polishing surfaces that with the first polishing surfaces define a polishing face.

49. (New) The pad of claim 48, wherein the plurality of first and second sections are provided in an alternating arrangement.

- 50. (New) The pad of claim 46, wherein the first material comprises a matrix material containing the abrasive first material, the abrasive first material being more abrasive than the matrix.
- 51. (New) The pad of claim 50, wherein the matrix material is substantially nonabrasive.
  - 52. (New) The pad of claim 50, wherein the matrix material is abrasive.
- 53. (New) The pad of claim 46, wherein the second material is substantially nonabrasive.
- 54. (New) The pad of claim 46, wherein the second material is substantially nondegradable.

55. (New) A polishing pad for polishing a surface, comprising:

a first member defining a first polishing surface and comprising a structurally degradable abrasive first material, the abrasive first material being randomly distributed throughout the first member;

a second member defining a second polishing surface; and

an opposing side formed from at least one of the first member and the second member, wherein the first polishing surface is capable of being extended beyond the second polishing surface by a fixed amount.

56. (New) The pad of claim 55, wherein:

the first member includes a plurality of first sections having first polishing surfaces; and,

the second member includes a plurality of second sections having second polishing surfaces that with the first polishing surfaces define a polishing face.

- 57. (New) The pad of claim 56, wherein the plurality of first and second sections are provided in an alternating arrangement.
  - 58. (New) The pad of claim 55, wherein:

the second member includes a second material that is more soluble in a solvent than the first material.

59. (New) A polishing pad for polishing a surface, comprising:

a first member having a structurally degradable abrasive first material, the abrasive first material being randomly distributed throughout the first member; and

a second member having a second material that is less degradable and less abrasive than the first material;

at least a portion of the first member capable of being extended beyond the second polishing surface by a fixed amount.

- 60. (New) The pad of claim 59, further comprising an opposing side formed from at least one of the first member and the second member.
  - 61. (New) The pad of claim 59, wherein:

the first member includes a plurality of first sections having first polishing surfaces; and

the second member includes a plurality of second sections having second polishing surfaces that with the first polishing surfaces define a polishing face.

- 62. (New) The pad of claim 61, wherein the plurality of first and second sections are provided in an alternating arrangement.
- 63. (New) The pad of claim 59, wherein the second member includes a second material is more soluble in a solvent than the first material.

- 64. (New) The pad of claim 59, wherein the second material is substantially nonabrasive.
- 65. (New) The pad of claim 64, wherein the second material is substantially nondegradable.